Ion Beam Center

Institute of Ion Beam Physics and Materials Research

## **Experimental Plan – Ion Implantation / Irradiation**

(Please provide a detailed description of the planned experiment including relevant technical details. Please describe your sample(s) in detail including quantity, size, composition, ... Use font Arial, 11 pt.)

## Title of the proposal

Implanted <sup>19</sup>F targets for high current cross section measurement at LUNA

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## Ion implantation / irradiation conditions

sample name	mater ial	Size (mm)	side	ion species	energy (keV)	fluence (cm <sup>-2</sup> )	temperature (°C)	tilt angle (°)	twist angle (°)
DP1-DP3	Та	40	front	F-19	325	7.7x10 <sup>17</sup>	watercooled	0	0
DP1-DP3	Та	40	front	F-19	110	1.5x10 <sup>17</sup>	watercooled	0	0
DP1-DP3	Та	40	front	F-19	45	8x10 <sup>16</sup>	watercooled	0	0
DP4-DP6	Та	40	front	F-19	500	6.3x10 <sup>17</sup>	watercooled	0	0
DP4-DP6	Та	40	front	F-19	200	2.5x10 <sup>17</sup>	watercooled	0	0
DP4-DP6	Та	40	front	F-19	80	7.5x10 <sup>16</sup>	watercooled	0	0
DP4-DP6	Та	40	front	F-19	30	4.5x10 <sup>16</sup>	watercooled	0	0

## **Further remarks**

Ta foil thickness= 0.25 mm, provided by LUNA collaboration, shape and size in Fig. 1 Fe foil thickness= 0.25 mm, provided by LUNA collaboration, shape and size in Fig. 1

DP1-DP3 targets should have a final thickness of 250 nm, with 40-50% concentration of F-19 DP3-DP6 targets should have a final thickness of 510 nm, with 40-50% concentration of F-19 from 0 to 400 nm

The necessary beam is about 3 hours per sample, so for 6 samples on Ta 18-20 shifts (8 hours each) are required.

Total fluence = 10<sup>18</sup> <sup>19</sup>F / cm<sup>2</sup>

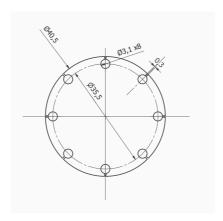


Fig.1